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| APPLICATION NUMBER | FILING or 371(c) DATE | GRP ART UNIT | FIL FEE REC'D | ATTY. DOCKET NO | TOT CLAIMS | IND CLAIMS |
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CONFIRMATION NO. 4496

CORRECTED FILING RECEIPT

25944
OLIFF & BERRIDGE, PLC
P.O. BOX 19928
ALEXANDRIA, VA22320

Date Mailed: 03/23/2007

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Power of Attorney: The patent practitioners associated with Customer Number 25944

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/16887 12/26/2003

Foreign Applications

JAPAN 2002-379963 12/27/2002

If Required, Foreign Filing License Granted: 05/16/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is
US10/539,569

Projected Publication Date: Not Applicable

Non-Publication Request: No

Early Publication Request: No

Title

Plasma generator, ozone generator, substrate processing apparatus and manufacturing method of semiconductor device

Preliminary Class

438

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